

# Growth and texturing of rare earth nitride thin films

#### Q2.3 MRS 26 November 2007

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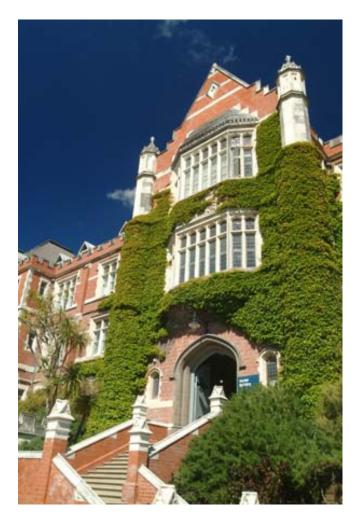
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#### Victoria University of Wellington

- Ben Ruck
- Jianping Zhong
- Claire Meyer (Q10.6)
- Joe Trodahl
- Canterbury University (PLD)
- Steve Durbin
- Ian Farrell



Victoria



#### Rare earth nitrides

- Across the RE series you get very...
  - similar chemical properties (5d and 6s electrons)
  - different magnetic properties (unfilled 4f shell)
- React with water in atmosphere

Th Pa U hote brakes trakes

- Need to passivate with capping layer





#### Rare earth nitrides

- Interesting questions
  - Electronic structure calculations are challenging
    - · localized 4f electrons are tough to deal with
    - Many different predictions
    - Metallic, half-metallic and semi-conducting states predicted
  - Magnetic ordering
    - SmN magnetism
      - Small magnetic moment, magnetic ordering
      - see Claire Meyer Q10.6
- Very clear need for experimental results



#### Growth methods

- MBE
  - Gerlach et al, Appl. Phys. Lett. 90, 061919 (2007)
- $RE(NH_2)_2 -> REN$

- Imamura et al, J. All. Comp. 16169 (2007)

- Reactive Ion-Beam sputtering

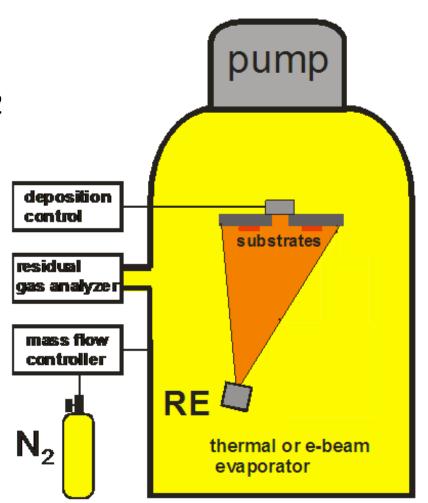
   *Leuenberger et al*, PRB 72, 014427 (2005)
- Thermal evaporation (VUW)
   Granville et al, PRB 73, 235335 (2006)

#### Thermal evaporation

- UHV
- Partial pressure of N<sub>2</sub> gas

$$-P_{N_2} \sim 10^{-4}$$
mbar

- This works!
- GaN or MgF<sub>2</sub>
   capping layer



**UHV system** 

Victoria

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#### Characterization

- SmN, GdN, DyN, ErN, LuN
- Good 1:1 stoichiometry  $\pm$  2% (RBS)
- Low O content, uniform films (SIMS)
- Semiconducting (transport)

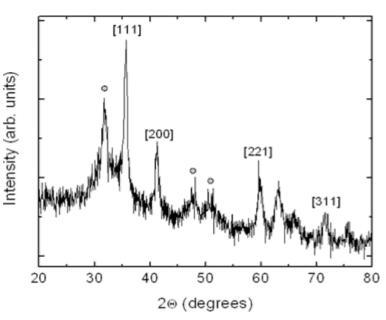


#### Characterization - XRD

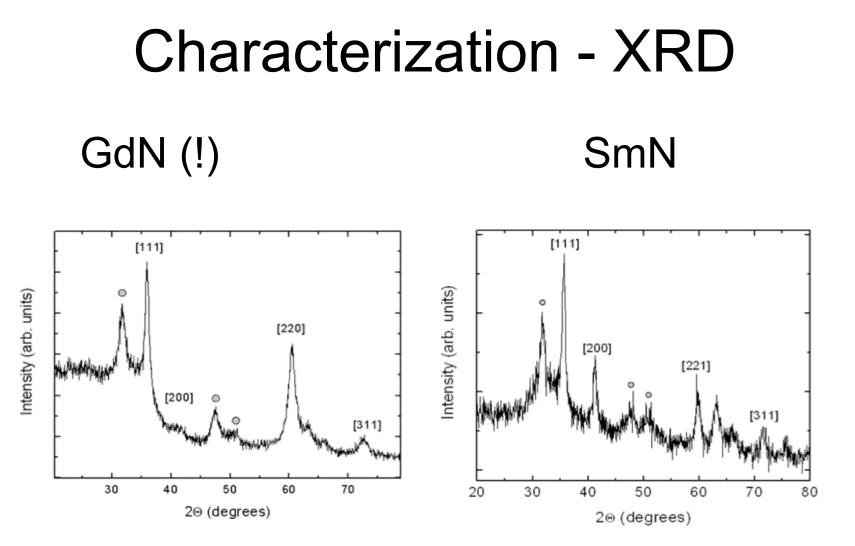
Typical REN



 Randomly oriented nanocrystals (~10nm)



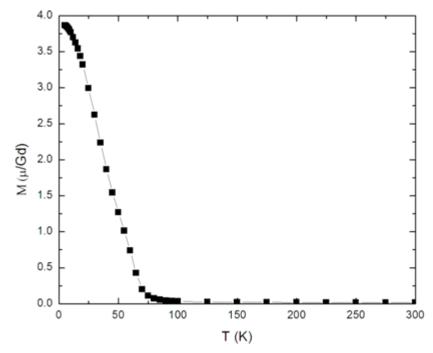






#### Characterization

- Clear magnetic transitions (GdN: 70K)
- Coercive field ~ 250 Oe

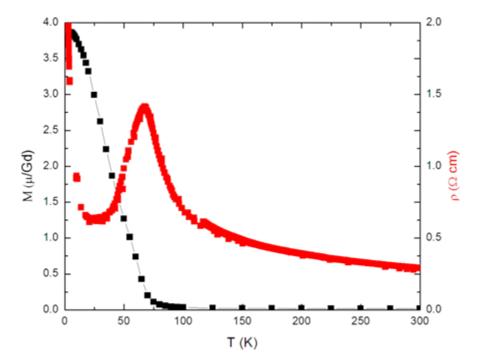


Granville et al, "Semiconducting ground state of GdN thin films" Phys. Rev. B, **73**, 235335 (2006)



#### Characterization

- Semiconducting behaviour
  - smaller gap in ferromagnetic ground state



Granville et al, "Semiconducting ground state of GdN thin films" Phys. Rev. B, **73**, 235335 (2006)



## Pulsed Laser Deposition (PLD)

- Laser ablation of RE metal source
- Similar to thermal evaporation techniques except that evaporation rate is time dependant (depends on pulse frequency)
- Main advantages
  - Can grow at elevated temperature
  - Novel capping materials possible
  - RHEED for *in situ* characterization



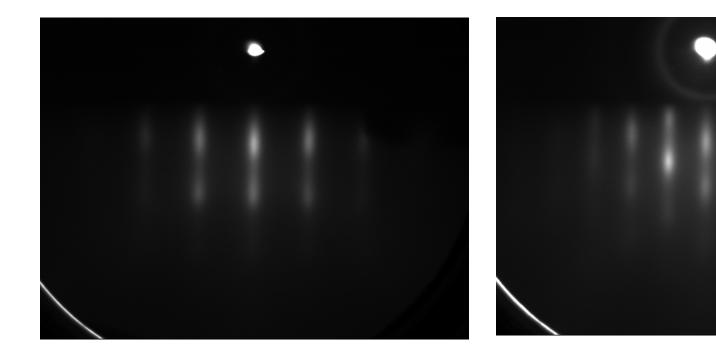
#### PLD - GdN

- Have grown thin films of GdN
- At elevated temperatures: ~700° C
- Substrates: Si, Sapphire, YSZ
- Capping layer: YSZ



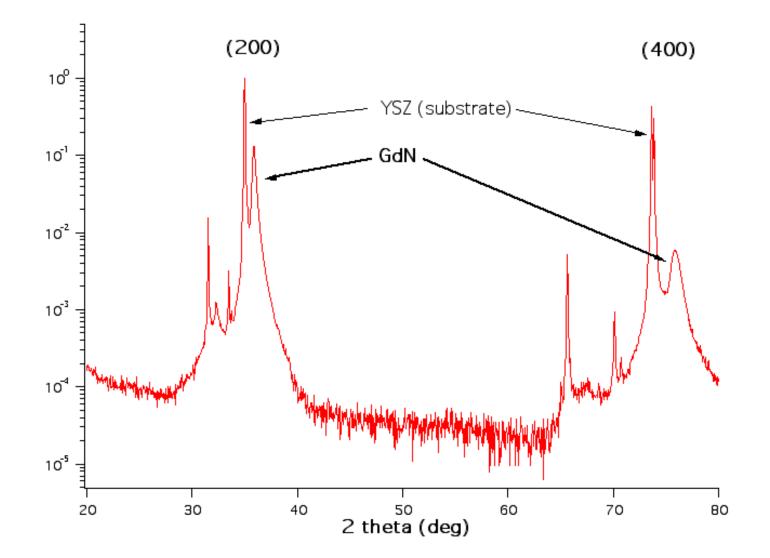
#### **Characterization - RHEED**

RHEED taken along 2 different directions
 Match RHEED of substrates (in-plane epitaxy)





#### **Characterization - XRD**





#### Characterization - Magnetic

- Magnetization saturates at very small field strengths
- Coercive field ~ 20 Oe
  - Order of magnitude smaller than thermal samples



### Many parameters to explore

- Rare earths
- Substrates
  - Si
  - YSZ (lattice matched, but oxygen is a worry)
     Sapphire
- Growth temperature
- Growth pressure
- Activated N<sub>2</sub>
- Capping layers



#### Summary

- Both theory and measurements of nanocrystalline films indicate interesting properties
- Further advances require quality epitaxial films before they can be answered
- This has been achieved as a proof of concept
- Much more work to do



#### Thank You

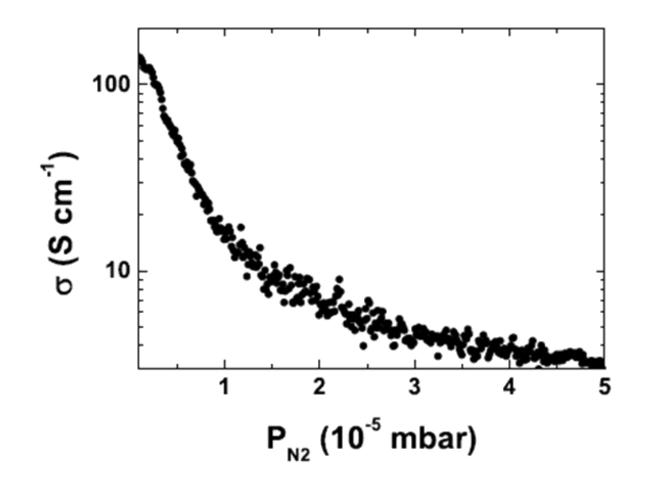
#### Claire Meyer (Q10.6) Magnetic properties of REN thin films



#### Appendix

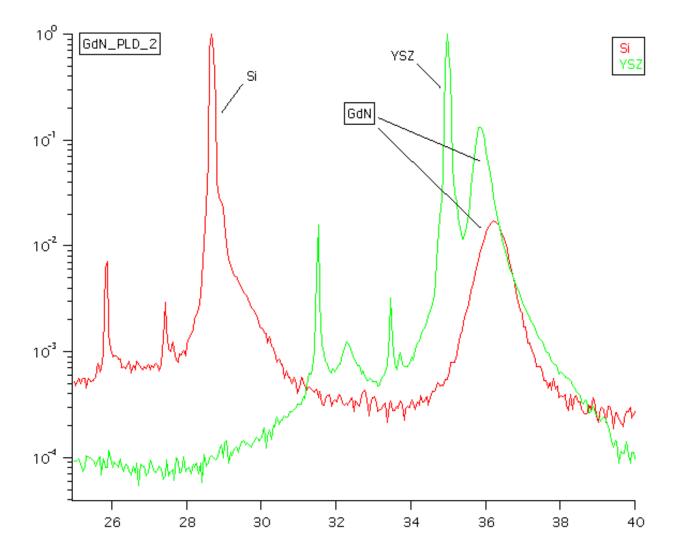


#### Extra Info - N<sub>2</sub> Pressure



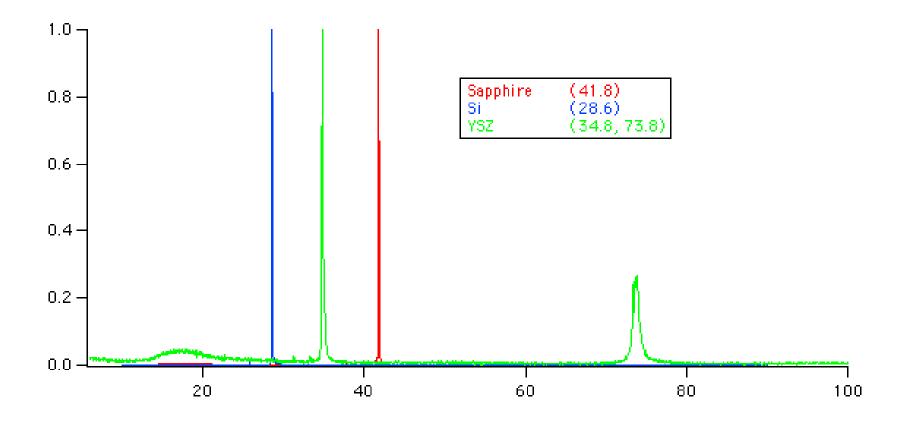


#### Extra Info - PLD XRD





#### Extra Info – Substrates

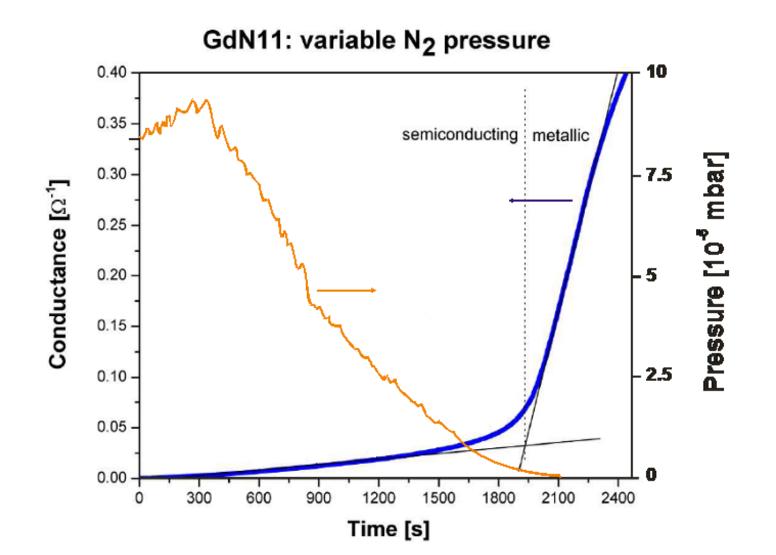




#### Extra Info – RBS



#### Extra Info – N<sub>2</sub> content





#### Extra Info – SIMS profile

• N<sub>2</sub> GdN (GaN cap)

